

IEEE SW Test Workshop

Semiconductor Wafer Test Workshop

June 12 to 15, 2011 San Diego, CA

A Flexible Vertical MEMs Probe Card Technology for Pre-Bump and eWLP Applications



Mike Slessor Rick Marshall (MicroProbe, Inc.)

Vertical MEMS for Pre-Bump Probe

- Introduction: eWLP and Pre-Bump Probing Requirements
- Experiment Objectives & Details
 - Accurate Probing on Small Pads at Fine Pitch
 - Low Scrub Depth on Pre-Bump Pads
 - Wafers Probed & Measurements Taken
- Observed Probe Results & Conclusions
 - Accuracy & Repeatability Across Wafer
 - Measured Scrub Depth Results
 - Reliable Enabling of Pre-Bump Probing for Improved eWLP Yields
- Follow-On Work
 - Production Characterization in Large Volume
- Summary



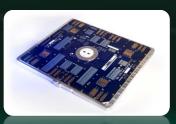
MicroProbe: A Leading Supplier of Logic/RF/SoC Probe Card Solutions

Innovation and Growth

- Technology Leadership
 - >1000 MEMS probe cards delivered
- Market Share Growth
 - #1 supplier of Advanced SoC Probe Cards
- Customer Collaboration
 - 35-year history of delivering results









Breadth and Stability

- Broad Product Portfolio
 - Cantilever, Vertical, and MEMS
- Global Presence
 - Major facilities in China, Taiwan, US
- Strong Institutional Investors
 - Flywheel Ventures, Gemini Investors, Intel Capital



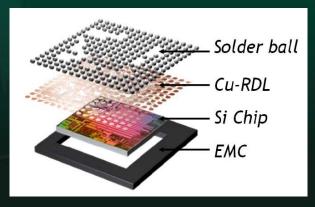
eWLP Resurrects Pre-Bump Array Probing

- While pre-bump probing has been largely eliminated from mature BGA Flip-Chip packaging flows, the workflow and cost considerations of eWLP are re-introducing need for effective pre-bump probing on arrays of aluminum pads.
- Today's designs challenge probing on multiple fronts:
 - Full-grid array layout at ~100um pitches → Vertical Architecture
 - Small pads and pad openings → Small Scrub
 - Low-k dielectrics and under-pad circuitry → Low Force
- Experimental work demonstrates that MicroProbe's MEMS
 Vertical probe solution addresses today's pre-bump probe
 requirements, enabling cost-effective implementation of
 newly developed eWLP-based packaging flows.



What is eWLP?

- eWLP = "Embedded Wafer Level Packaging"
- eWLP is an evolution of BGA-type packaging that uses molded carriers and fan-out RDLs. The original die are singulated, embedded into molded carriers, and then reconstituted onto artificial wafers. Wafer-level processes then add redistribution layers (RDLs) and solder balls
- This approach enables both a higher level of interconnects per die area (due to the fan-out RDL) and enables greatly simplified multi-chip integration.
- Also known as eWLB (Wafer-Level BGA) and FO-WLP (Fan-Our WLP)



A Simplified eWLP Stack-Up



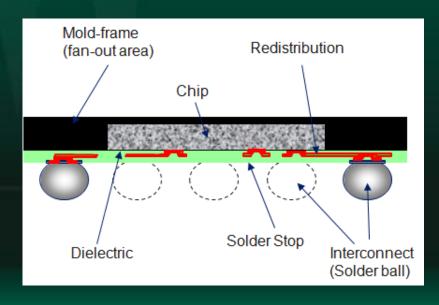
eWLP and Pre-Bump Probe

 Packaging bad die into molded carriers, and subsequently attaching them to reconstituted wafers, causes very expensive yield loss for the final eWLP wafer.

 For multi-die eWLP packages, the cost impact is even worse – the problem is directly analogous to test escapes finding their way

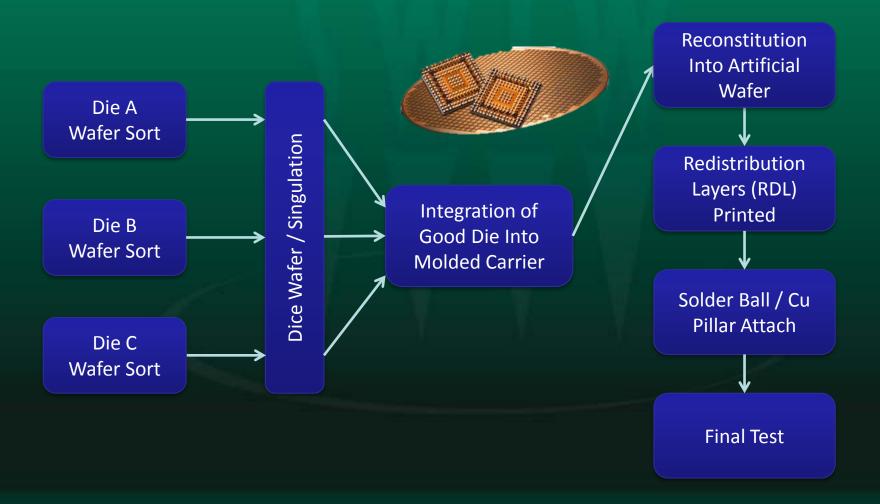
into a multi-chip module.

 Because of these considerations, effective test of the target die prior to singulation is imperative to ensure good yield at final test.





Example eWLP Test Flow





Pre-Bump Probe Challenges

Fine Pitch in Full Grid Arrays

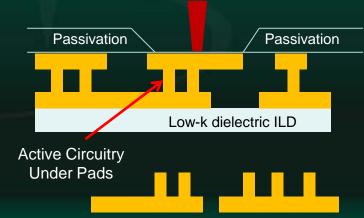
 RDL fan-out permits increasingly fine pitch across high pincount arrays. Today's arrays are 130um – 180um. Next generation arrays will be < 100um.

Small Pads

 Bond pad openings are getting smaller: 50um octagonal pads are migrating towards 40um

Low Force

 CUP and Low-K require very low force contact on the pad material to ensure there is no IC damage

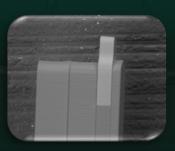




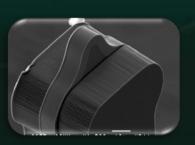
MicroProbe Vertical MEMS "Mx" Probe Architecture

- Composite MEMS structure allows optimization of mechanical and electrical design
 - Multiple materials & Layers
 - Photolithographically Defined Shape
- Resulting material & geometry flexibility provides optimal contact performance and pitch scalability





Mx-FP Probe Low-K / CUP



Pointed Probe
Al & Cu Pads



Flat Probe Cu Pillars, Bumps



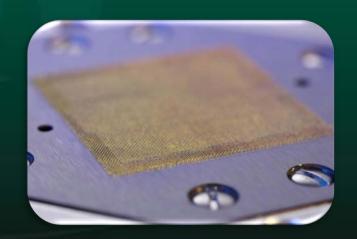
Customer Experiments with Mx for Pre-Bump Probing

 Customer A: Focus on low force contact to minimize pressure applied to circuit under pad

Customer B: Focus on good contact with minimal

scrub depth into pad material

 Customer C: Focus on probe tip accuracy for contacting small pads with high precision and repeatability



Example Mx Probe Head with > 10K MEMS Probes



Customer A: Low Force Experiment

Wafer Setup for Experiment

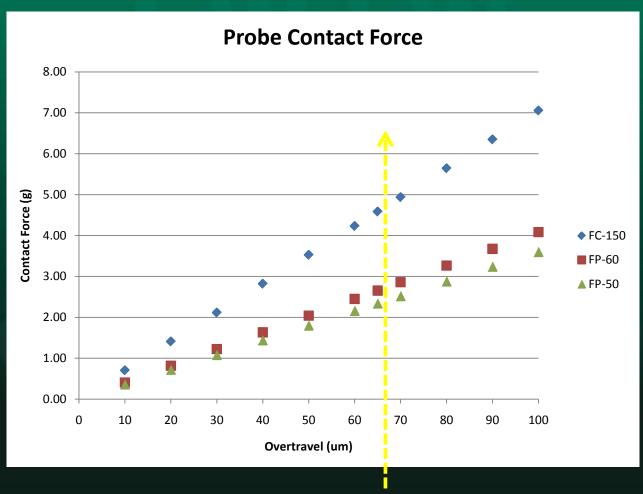
- 300mm wafer at 40nm process
- eWLP pre-bump pads probing
- 60um octagonal pads

Evaluation Criteria

- Cres must be within acceptable range for device
- Probe force over active area and low-k ILD must be minimal
- Scrub mark must be small and repeatable



Mx Probe Contact Force at Overtravel



Recommended OT = 65um



Mx Low-Force Design & Modeling

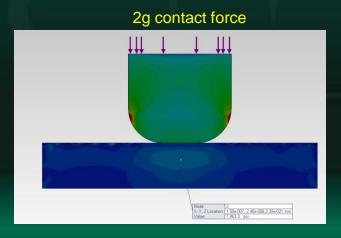
MEMS Geometry & Metallurgy

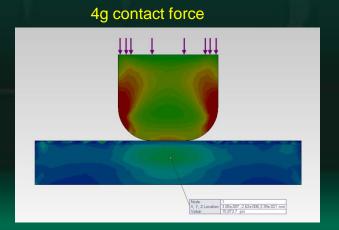
- Proprietary Mx MEMS process enables multi-layer probe design with lithographically defines shapes
- Focused on low-force mechanical design
 while maintaining excellent Cres characteristics



Design & Modeling

- Detailed FEA models are developed to predict scrub stress behavior
- Model predictions are continually refined based on real-world observation

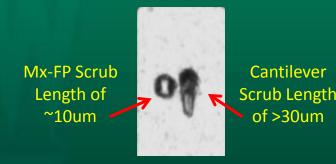




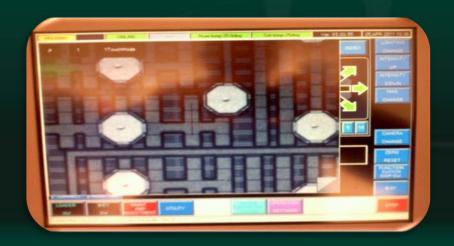


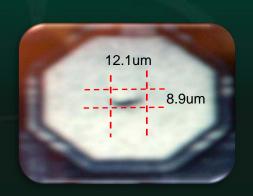
Customer A: Low Force Findings

- Mx scrub mark ranges 8um 15um
- Maximum scrub depth of 0.55um
 - (After 8 touchdowns)



No ILD cracking found with 60um over-drive

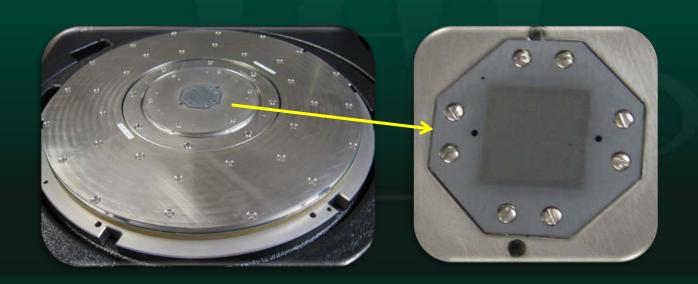






Customer B: Small Pads Experiment

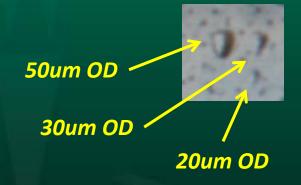
- Test Setup for Experiment
 - ≈180 Die Per Wafer
 - ≈ 7,500 Pads Contacted per Die
 - 55um Pads in 180um Array
 - TEL P12Ln Prober with Test Temperature of 40degC





Scrub Mark Size & Accuracy

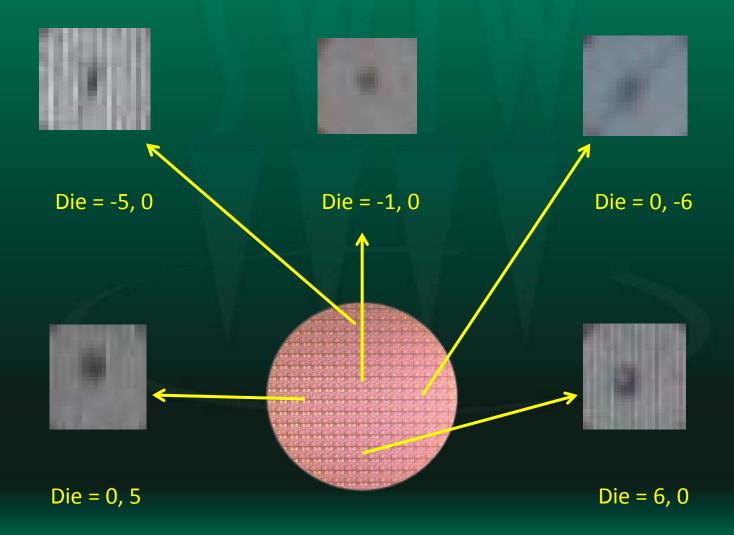
- Customer Findings on Scrub Mark Placement
 - Typical accuracy to pad center: +/- 9um
 - Worst-case accuracy observed: +20um
 - (Mx Typical Spec = +/-13um)
- Customer Findings on Scrub Mark Size
 - 20um OD → 7um Scrub
 - -30um OD $\rightarrow 10$ um Scrub
 - 50um OD \rightarrow 11um Scrub
 - 65um OD \rightarrow 15um Scrub
 - (Mx Recommended OD = 65um)







Accuracy & Repeatability Across Wafer





June 12 to 15, 2011

Customer B: Small Pads Findings

- Mx solution delivers highly-accurate and repeatable scrub marks that are suitable for pre-bump probing small pads
 - Overall planarity of a large array was very good (< 24um)
 - Probe mark placement was very accurate, consistently placing the scrub center within +/- 13um. (One outlier was observed.)
 - Placement across 300mm wafer was extremely repeatable
 - Tip recognition, cleaning requirements, etc., are production-worthy



Customer C: Scrub Depth Experiment

Wafer Setup for Experiment

- 300mm qual wafer selected in Engineering lab
- Entire wafer probed with 4 touchdowns on every die
- Lower 2/3 probed with a 5th touchdown
- Lower 1/3 probed with a 6th touchdown

Scrub Mark Review Techniques

- Center and edge samples collected from each zone
- Angled photos taken to profile scrub mark shape
- Passivation cap added to enable FIB cross-sectioning
- Scrub depth into Aluminum directly measured

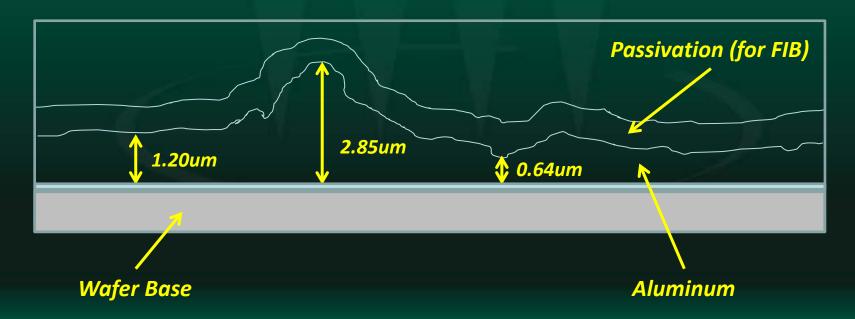




Customer C: Scrub Depth Findings

Pad Scrub Findings

- Starting aluminum depth of 1.20um
- Worst-case image: 6 touchdowns at wafer center
- Aluminum depth of 0.64um shows maximum scrub depth of 0.56um
- Low scrub was very repeatable across all wafer zones





Conclusions & Use Benefits

Conclusion

 The Mx MEMS vertical probe solution addresses key requirements for today's pre-bump probing: low-force, high-accuracy contact, repeatability, and low force. These characteristics can enable effective pre-bump probe for the next generation of pads testing.

Use Benefits

- Flows such as eWLP can significantly reduce packaging costs by ensuring only known good die are put into molded carriers & reconstituted wafers
- Yield learning & improvement can be accelerated by bringing "first look" closer to the wafer fab no need to wait for bumping to see low yield
- Long-term quality & reliability of pads-tested devices can be improved by reducing the risk that under-pad circuitry is stressed or damaged



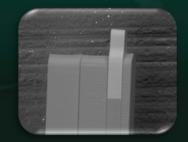
Follow-On Work / Q&A

Follow-On Work

- Lifetime testing on accuracy and scrub would be beneficial to understand
 MEMS stability and repeatability versus legacy solutions
- Copper pads testing should be conducted these studies were all done using Aluminum pads
- Additional hot-temp testing would be useful, as would a cold-temp study

Questions?





Mx-FP

